

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Robert P. Meagley et al.

Serial No.: 10/688,521

Filed: October 17, 2003

For: Reducing Photoresist Line Edge  
Roughness Using Chemically-  
Assisted Reflow

§ Group Art Unit:

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§ Examiner:

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§ Atty. Dkt. No.: ITL1026US (P16713)

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

INFORMATION DISCLOSURE STATEMENT


Dear Sir:

Applicant submits the references listed on the attached form PTO 1449 together with any required copies of such references.

This statement is being filed before the receipt of a first Office action on the merits. Please apply any charges or credits to Deposit Account 20-1504.

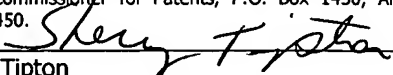
Respectfully submitted,

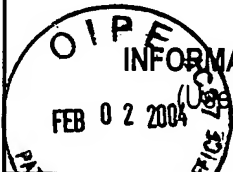
Date: January 29, 2004

  
Timothy M. Trop, Registration No. 28,994  
TROP, FRUNER & HU, P.C.  
8554 Katy Freeway, Suite 100  
Houston, Texas 77024  
(713) 468-8880 [Phone]  
(713) 468-8883 [Fax]

Date of Deposit: January 29, 2004

I hereby certify under 37 CFR 1.8(a) that this correspondence is being deposited with the United States Postal Service as **first class mail** with sufficient postage on the date indicated above and is addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

  
Sherry Tipton

	<b>ATTY DOCKET NO.</b> ITL1026US (P16713)		<b>SERIAL NO.</b> 10/688,521
	<b>INFORMATION DISCLOSURE CITATION</b> (Use several sheets if necessary)		
	<b>APPLICANT(S):</b> ROBERT P. MEAGLEY ET AL.		<b>FILING DATE:</b> October 17, 2003
			<b>GROUP ART UNIT:</b>

### U.S. PATENT DOCUMENTS

*EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	A.						
	B.						
	C.						
	D.						
	E.						
	F.						
	G.						
	H.						
	I.						

### FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							YES	NO
	J.							
	K.							
	L.							
	M.							
	N.							
	O.							
	P.							

### OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

	Q.	Robert P. Meagley and Michael D. Goodner, U.S. Patent Application Serial No. 10/679,793, filed 10/06/2003, entitled "Increasing the Etch Resistance of Photoresists"
	R.	
	S.	
	T.	
	U.	
	V.	
	W.	

<b>EXAMINER</b>	<b>DATE CONSIDERED</b>
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\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.